

10/529412

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Thomas Hecht et al.

JC17 Rec'd PCT/PTO 29 MAR 2005

Serial No.: Unknown
(Priority Application No. DE 102 45 537.6)
(International Application No. PCT/DE03/03188)

Filed: Herewith
(Priority Date: September 30, 2002)
(International Filing Date: September 24, 2003)

Docket No.: I433.153.101/13.555

Title: METHOD AND PROCESS REACTOR FOR SEQUENTIAL GAS PHASE
DEPOSITION BY MEANS OF A PROCESS CHAMBER AND AN
AUXILIARY CHAMBER (As Amended)

PRELIMINARY AMENDMENT

Mail Stop PCT
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

This Preliminary Amendment amends the Utility Patent Application filed herewith and should be used to calculate filing fees due. Prior to examination of the above-identified patent application, please amend as follows: